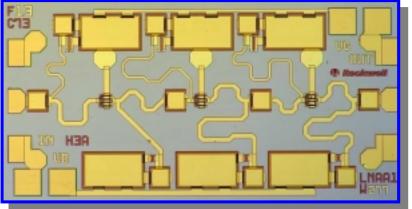
Rockwell Science Center

KLNA3S.01R***



MMIC Features

- Low Noise 2.5 dB N.F.
- **High Gain 24 dB Gain (min)**
- □ Frequency Range : 26-30 GHz
- **50** Ω Zin / Zout
- > 10 dB Input / Output Return Loss
- > 8 dBm Output power at 1dB gain compression
- Chip size : 1.5 mm X 0.7 mm
- **Substrate Thickness : 75 μm**
- **Bond Pad dimensions 100 μm x 100 μm**

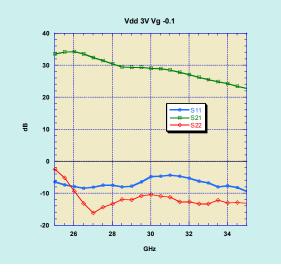
Description

The Rockwell KaLNA3S.04R is a PHEMT low noise amplifier that operates from 26 to 30 GHZ. This 3 stage amplifier has 26 dB nominal gain with 2.5 dB nominal noise figure and 1 dB gain compression of 8 dBm output power minimum. This MMIC is unconditionally stable.

Absolute Maximum Ratings

Symbol	Parameters/Conditions	Min	Мах	Units
V _d 1 2 3	Drain Supply Voltage		5	Volts
V _g 1 2 3	Gate Supply Voltage	-0.6	0.0	Volts
ld total	Total drain current		80	mA
lg total	Total gate current		0.1	mA
Pin	RF input power		30	dBm
T ch	Operating channel temperature		150	° C
T max	Max assembly temperature		300*	° C
T stg	Max storage temperature	- 65	165	° C
T base	Maximum base plate temperature		140	° C

* 30 minute maximum





Symbol	Parameters/Conditions	Min	Тур	Мах	Units
V _d 1 2 3	Drain Supply Voltage	2.5	3	5	Volts
V _g 1 2 3	Gate Supply Voltage	-0.6	-0.2	0.0	Volts
ID total	Total drain current (@ typ Vgs)	20	50	80	mA
Frequency	Specified Bandwidth edges	26		30	GHz
Gain**	Small signal	24	26		dB
Δ Gain	Small signal gain flatness			1	dB/GHz
P1dB(note 1)	Power output at 1dB gain compression	8	10		dBm
RL in	Input port return loss	8	10		dB
RL out	Output port return loss	8	10		dB
Isolation	Reverse isolation	30	40		dB
NF(note 1)	Noise figure		2.2	2.8	dB

RF and Electrical Specifications Conditions T base = 25 ° C, Z source = Z load 50 +/- 5 Ω

(Note 1) These measurements will be carried out on a sampled basis. A random representative sample of dies is mounted and tested for noise figure and 1 dB gain compression.

- □ Each die is fully DC tested and RF S-parameters are measured. Full 2-port S-parameter data on individual die will be supplied.
- All dies will pass visual inspection as dictated by the rules contained in Section A of the General Notes on Rockwell PHEMT Products (applicable sections of MIL-I-45208)
- Every die has a unique identifier number on-chip for complete traceability.
- A conductive epoxy or a flux-less solder die attach is recommended. The die should be attached to an electrically conductive surface to complete DC and RF ground paths. The ground path inductance should be minimized (<10 pH) to assure stability.</p>
- □ The front side metal is compatible with thermo-sonic 1 mil wire bonding. The backside metal is compatible with die attach methods not exceeding Tmax .
- GaAs MMICs are ESD sensitive. Proper precautions should be used when handling these devices.
 Front and backside metal is Gold.
- In the event of performance verification, dies will be mounted and tested in a standard Rockwell approved test fixture for Ka band. (See Section B of the General Notes on Rockwell PHEMT Products).
- (***) Rockwell Science Center reserves the right to make improvements in this device, including die size reduction, while maintaining all RF & DC specifications. The General Notes on Rockwell PHEMT Products will be supplied upon user's request. In addition to inspection criteria it will contain descriptions, biasing instructions, reliability data.
- (**) Within the temperature range -35° C to +85° C, Small Signal Gain shall not vary by more than +/- 2.0 dB and shall remain within the range 21 dB to 27.5 dB. Under the same conditions the Noise Figure shall not exceed 3.2 dB.